

Notice of References Cited		Application/Control No. 10/690,315	Applicant(s)/Patent Under Reexamination YOO, WOO SIK	
		Examiner Asok K. Sarkar	Art Unit 2829	Page 1 of 1

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	B	US-6,043,004	03-2000	Kurimoto, Takashi	430/329
	C	US-6,231,775	05-2001	Levenson et al.	216/67
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	M	US-			

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NON-PATENT DOCUMENTS

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*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)
Dates in MM-YYYY format are publication dates. Classifications may be US or foreign.